

# Low-pressure plasma system V15-G

## Standard system for cleaning, activation and etching



View into the process chamber.

The system is integrated in a 19" rack, which is equipped with rollers and height-adjustable feet.

A professional PLC control unit serves as a storage for definable process parameters.

### **System features**

- USB port
- Ethernet interface
- Remote maintenance (VPN)
- Microwave coupling from the top
- Swing door

### **Options**

- Vacuum pump
- Ozone trap
- Up to three additional gas inlets
- Additional excitation frequencies (40 kHz, 13.56 MHz)
- Rotary drum for the treatment of bulk material
- Rotary table
- Lateral microwave coupling
- Soft start and slow vent

### Technical data

Dimensions of the system (W x D x H):  $670 \times 900 \times 1,850$  mm Dimensions of the chamber (W x D x H):  $250 \times 250 \times 250$  mm

Plasma excitation frequency: Microwave (2.45 GHz)

Microwave power: 100-600 W

Gas inlets with mass-flow-control: 1 channel

Power supply: 230/400 V, 50/60 Hz

Power input: 1.5 kVA Vacuum gauge: Pirani

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Am Kessler 6 97877 Wertheim Germany T +49 (0) 93 42 919-0 F +49 (0) 93 42 919-111 plasma-finish@pink.de www.pink.de The standard system V15-G is designed for the industrial small series production as well as for the low-pressure plasma treatment in R&D laboratories.